

In the Claims

[Claims 1-13 are canceled.]

D' 14. [Second Amendment] ~~An electronic device wafer processing intermediate member adapted to receive an electronic device wafer having an electrical coupling and couple with a chuck having an electrical coupling, the intermediate member comprising:~~
~~an electrical interconnect configured to electrically connect the electrical coupling of the electronic device wafer with the electrical coupling of the chuck.~~

An article of manufacture comprising:

an electronic device wafer processing intermediate member adapted to receive an electronic device wafer having an electrical coupling and couple with a chuck having an electrical coupling, the intermediate member comprising:
an electrical interconnect configured to electrically connect the electrical coupling of the electronic device wafer with the electrical coupling of the chuck.

15. [Second Amendment] ~~The electronic device wafer processing intermediate member~~ article according to claim 14 wherein the intermediate member includes a plurality of electrical interconnects configured to electrically connect a plurality of electrical couplings of an electronic device wafer and a chuck.

16. [Second Amendment] ~~The electronic device wafer processing intermediate member~~ article according to claim 14 wherein the electrical interconnect comprises a pogo pin.

17. [Second Amendment] The ~~electronic device wafer processing intermediate member~~ article according to claim 14 wherein the electrical interconnect comprises a wire.

[Claims 18-52 are canceled.]

53. [Amended] The ~~electronic device wafer processing intermediate member~~ article according to claim 14 wherein the intermediate member comprises a substantially electrically nonconductive material.

54. [Previously Added] A wafer processing apparatus comprising:
an intermediate member comprising:
a first surface configured to support substantially an entirety of an electronic device wafer;
a first electrical coupling adjacent to the first surface and configured to electrically connect with an electrical coupling of the electronic device wafer;
a second surface opposite to the first surface;
a second electrical coupling adjacent to the second surface and configured to electrically connect with an electrical coupling of a chuck of the wafer processing apparatus; and
an electrical interconnect configured to electrically connect the first electrical coupling with the second electrical coupling and to communicate electrical signals between the first electrical coupling and the second electrical coupling.

55. [Previously Amended] The apparatus of claim 54 further comprising the electronic device wafer comprising the electrical coupling configured to electrically connect with the first electrical coupling of the intermediate member.

56. [Previously Added] The apparatus of claim 55 wherein the wafer has a surface, and an outwardly exposed surface of the electrical coupling of the wafer is substantially coplanar with the surface of the wafer.

57. [Previously Added] The apparatus of claim 54 wherein the intermediate member comprises a substantially electrically nonconductive material.

58. [Previously Added] The apparatus of claim 54 wherein the intermediate member includes a plurality of electrical interconnects configured to electrically connect a plurality of electrical couplings of the wafer and the chuck.

59. [Previously Added] The apparatus of claim 54 wherein the electrical interconnect comprises a pogo pin.

60. [Previously Added] The apparatus of claim 54 wherein the electrical interconnect comprises a wire.

61. [Previously Added] A wafer processing apparatus comprising:

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an intermediate member comprising an electrical interconnect configured to electrically connect an electrical coupling of an electronic device wafer with an electrical coupling of a chuck of the wafer processing apparatus, and wherein the electrical interconnect is configured to communicate electrical signals intermediate the electrical coupling of the wafer and the electrical coupling of the chuck.

62. [Previously Amended] The apparatus of claim 61 further comprising the electronic device wafer comprising an electrical coupling configured to electrically connect with the electrical interconnect of the intermediate member.

63. [Previously Added] The apparatus of claim 62 wherein the wafer has a surface, and an outwardly exposed surface of the electrical coupling of the wafer is substantially coplanar with the surface of the wafer.

64. [Previously Added] The apparatus of claim 61 wherein the intermediate member comprises a substantially electrically nonconductive material.

65. [Previously Added] The apparatus of claim 61 wherein the intermediate member includes a plurality of electrical interconnects configured to electrically connect a plurality of electrical couplings of the wafer and the chuck.

66. [Previously Added] The apparatus of claim 61 wherein the electrical interconnect comprises a pogo pin.

67. [Previously Added] The apparatus of claim 61 wherein the electrical interconnect comprises a wire.

68. [Amended] The ~~electronic device wafer processing intermediate member~~ article according to claim 14 wherein the electrical interconnect is configured to electrically connect the electrical coupling of the electronic device wafer with the electrical coupling of the chuck of an electronic device wafer processing apparatus.

69. [Previously Added] The apparatus of claim 54 wherein the intermediate member is configured to support a wafer for processing within the ^{NAB} wafer processing apparatus to form a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

70. [Previously Added] The apparatus of claim 54 wherein the intermediate member is configured to expose a wafer to a processing environment within the wafer processing apparatus to form a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

71. [Previously Added] The apparatus of claim 54 further comprising a processing area configured to process a wafer supported using the intermediate member to fabricate a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

72. [Previously Added] The apparatus of claim 54 wherein the wafer processing apparatus is configured to process a wafer supported using the intermediate member to fabricate a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

73. [Previously Added] The apparatus of claim 54 wherein the wafer comprises a semiconductive wafer.

74. [Previously Added] The apparatus of claim 55 wherein the electronic device wafer comprises a plurality of integrated circuit dies prior to singulation of at least one of the dies at a subsequent moment in time.

75. [Previously Added] The apparatus of claim 61 wherein the intermediate member is configured to support a wafer for processing within the wafer processing apparatus to form a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

76. [Previously Added] The apparatus of claim 61 wherein the intermediate member is configured to expose a wafer to a processing environment within the wafer processing apparatus to form a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

D' 77. [Previously Added] The apparatus of claim 61 further comprising a processing area configured to process a wafer supported using the intermediate member to fabricate a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

78. [Previously Added] The apparatus of claim 61 wherein the wafer processing apparatus is configured to process a wafer supported using the intermediate member to fabricate a plurality of discrete integrated circuits of a plurality of respective dies to be singulated from the wafer at a subsequent moment in time.

79. [Previously Added] The apparatus of claim 61 wherein the wafer comprises a semiconductive wafer.

80. [Previously Added] The apparatus of claim 62 wherein the electronic device wafer comprises a plurality of integrated circuit dies prior to singulation of at least one of the dies at a subsequent moment in time.
